

REMARKS

In reply to the Office Action of June 15, 2007, Applicant submits the following remarks.
Claims 1-2, 4, 11, 13, 17-18, 26, 28, 34 and 49-50 have been amended. Claim 51 is new.
Claims 3, 23-24 and 27 have been canceled.

Claim 1 has been amended to incorporate the subject matter of claim 23, as well as add silane and amine to the list of materials that can be in the first portion. Claim 26 has been amended to incorporate the subject matter of claim 27. Claim 50 has been amended to require an electrode layer disposed over the plurality of organic layers, which is supported in the specification as filed on page 13, lines 9-11. Claims 4, 13 and 17-18 have been amended to change their dependency to claim 1. Claims 28 and 34 were amended to change dependency to claims 26 and 36, respectively. Claims 2, 4 and 11 have been amended to better comport with amended claim 1. Claim 49 was amended to correct a typographical error. New claim 51 is supported by FIG. 2 and page 10, lines 9-11.

Applicant thanks the Examiner for finding claims 23, 26 and 27 to include allowable subject matter. Applicant respectfully requests reconsideration in view of the foregoing amendment and these remarks.

Reiterated Rejections

The Examiner reiterated the rejections of claims 26 and 29-49 over Endo in view of Kwong '179, over Kwong '038 in view of Kwong '179 and over Ito in view of Kwong '179 and the rejection of claims 26, 29-44, 46-48 and 50 over Towns. Applicant submits that now that claim 26 includes the limitations of objected to claim 27, that claim 26 and all the claims that depend therefrom are in condition for allowance. Therefore, applicant believes that the reiterated rejections are now moot.

New Rejections

Claims 1-4, 6, 7, 9-13, 15-22 and 24-25 were rejected under Towns in view of U.S. Patent No. 6,395,209 ("Yoshida"). Applicant respectfully disagrees in light of the amendment made to independent claim 1.

Claim 1 has been amended to incorporate the subject matter of claim 23, which was objected to by the Examiner. For this reason, applicant submits that claim 1 is now in condition for allowance. Applicant also added a silane and an amine to the list of possible materials in the first portion (in the second limitation of claim 1). Because Towns discloses a cross-linking agent, such as epoxy-silane (see office action, page 7) and the Examiner still found the subject matter of claim 1 and 23 together to be allowable, applicant believes that amended claim 1 is patentable over Towns and Yoshida, even with the broadening of the second limitation of the claim. Claims 2-4, 6, 7, 9-13, 15-22 and 24-25 depend from claim 1 and similarly allowable.

Claim 14 was rejected as unpatentable over Towns in view of Yoshida in further view of U.S. Patent No. 6,111,357 ("Fleming"). Claim 14 depends from claim 1 and applicant submits that claim 14 is patentable over the combination of Towns, Yoshida and Fleming for at least the reasons provided above with respect to claim 1.

Claim 50 was rejected as anticipated by U.S. Publication No. 2002/0106529 ("Okunaka"). Applicant respectfully disagrees.

Amended claim 50 is directed to an organic electronic device with a layer of resist with a pocket therein, the pocket defining a deposition region on a deposition surface, a plurality of organic layers including an emissive layer, wherein each said organic layer is in said deposition region on said deposition surface and an electrode layer disposed over the plurality of organic layers.

Okunaka describes a composition containing a high-molecular compound having as a photo-crosslinkable group, which is cross-linked by light irradiation via a mask to cure the composition to form photoemission layers (Abstract). The photoemission layers are formed using a photosensitive composition (paragraph 0157). A film 10 of the photosensitive composition is formed, dried, exposed and developed. To expose the film 10, light is directed

through a photomask 11 (FIG. 26B, paragraph 0162). Multiple pixels with photoemission layers 31-33 are formed using sequential deposition, exposure and development steps. The mask 11 is removed before a cathode 4 is applied to the patterned film (FIGS. 26D-26F).

Okunaka fails to suggest or disclose a device with a layer of resist. The photomask is not formed of resist. In fact, photomasks are typically not formed of a resist. Thus, claim 50's recitation of a resist does not read on Okunaka's mask. For at least this reason, applicant submits that claim 50 as amended is not anticipated over Okunaka. Applicant respectfully requests withdrawal of the anticipation rejection of claim 50.

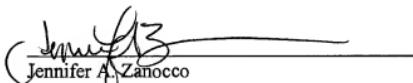
New Claim

Claim 51 is new and depends from claim 50. Applicant submits that new claim 51 is allowable for at least the reasons provided with respect to claim 50.

The two-month extension of time fee in the amount of \$460 is being paid concurrently herewith on the Electronic Filing System (EFS) by way of Deposit Account authorization. Please apply any other charges or credits to deposit account 06-1050.

Respectfully submitted,

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